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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN THE APPLICATION OF : Cella et al.
: **TELECHELIC EMISSIVE OLIGOMERS
AND POLYMERS DERIVED THEREFROM**

SERIAL NO. : 10/680,470
FILED : October 7, 2003
ART UNIT : 1711
ATTORNEY DOCKET NO. : 128493/GCRZ 2 00013

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

In accordance with 37 C.F.R. §§ 1.56, 1.97, 1.98 and MPEP § 609, Applicant submits the following Disclosure Statement concerning art of which the Applicant is aware. A copy of PTO-1449 is enclosed herewith.

This Information Disclosure Statement is not intended to constitute an admission that any patent, publication or other information referred to herein or submitted herewith is "prior art" for this invention unless specifically designated as such.

Under Rule 97(e)(1), the undersigned certifies that each item of information contained in this Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this statement and accordingly no fee is necessary. More particularly, each item was cited in the search report from corresponding International Application No. PCT/US2004/032914.

In accordance with 37 C.F.R. §1.97(g) and (h), the filing of this Information Disclosure Statement shall not be construed to mean that a search has been made or that no other material information as defined in 37 C.F.R. §1.56(b) exists.

Under § 1.98(a)(3), no concise explanation of relevance is required for information that is in the English language. Accordingly, the cited patents require no further explanation (or no translation is available).

It is respectfully requested that the documents cited be considered and officially cited in examination of this application.

The United States Patent and Trademark Office OG Notice dated 12 October 2004 published a final rule revising 37 C.F.R. 1.98 dealing with the content of Disclosure Statements. Paragraph (a)(2) was revised to read in part, "A legible copy of: (i) Each foreign patent; (ii) Each publication or that portion which caused it to be listed, other than U.S. patents and U.S. patent application publications unless required by the Office." Therefore, Applicant(s) has not enclosed copies of the cited U.S. patents and published patent applications with this Information Disclosure Statement.

Respectfully submitted,

FAY, SHARPE, FAGAN,
MINNICH & McKEE, LLP



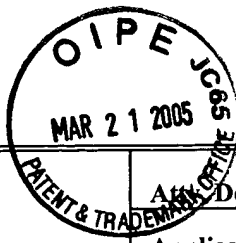
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CERTIFICATE OF MAILING

I hereby certify that this INFORMATION DISCLOSURE STATEMENT is being deposited with the United States Postal Service as first class mail in an envelope with sufficient postage addressed to: Commissioner of Patents, P.O. Box 1450, Alexandria, VA 22313 1450, on MARCH 16, 2005.

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Georgeen B. Sonntag



Subst. Form PTO-1449

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APPLICANT'S(S) INFORMATION
DISCLOSURE STATEMENT

Applicant(s): Cella et al.

Filing Date: October 7, 2003

Group: 1711

U.S. PATENT DOCUMENTS

Initial*		Document No.	Date	Name	Class	Subcl.	Filing Date
	AA	6,169,163	01/2001	Woo et al.			
	AB	5,516,877	05/1996	Bales et al.			
	AC						
	AD						
	AE						
	AF						

FOREIGN PATENT DOCUMENTS

		Document No.	Date	Country	Class	Subcl.	Translation?
	AG						
	AH						
	AI						
	AJ						
	AK						

OTHER ART

	AL	Scherf, U., List E.J.W., "Semiconducting Polyfluorenes - Towards Reliable Structure-Property Relationships" ADVANCED MATERIALS, vol. 14, no. 7, 2002, pages 477-487, XP002315008 cited in the application, page 479, left-hand column, paragraph 1; figures 3, scheme 2, scheme 5
	AM	
	AN	
	AO	
	AP	
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	AR	

Examiner:

Date Considered:

* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if in conformance and not considered. Include copy of this form with next communication to applicant.